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Reinvestigation of the Reaction between Triethylsilanol and Trimethylmethoxysilane

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Recently, a report appeared concerning the reaction of triethylsilanol with trimethylmethoxysilane as a model for the reaction of a glass surface with a silane coupling agent. A surprising result of that study was that Et₃SiOH and Me₃SiOMe reacted instantaneously upon mixing at room temperature in the absence of a catalyst. All previous reports had indicated that more vigorous conditions or the presence of a catalyst would be necessary to effect this reaction.2,3

We have reexamined the reaction between Et₃SiOH and Me₃SiOMe and have concluded that they do not react spontaneously at room temperature. We have shown that the presence of a chlorosilane contaminant, which may have been undetected in the previous study, will cause a fast reaction to occur.

Dreyfuss reported that within 10-15 s of mixing Et₃SiOH and Me₃SiOMe at room temperature, the solution became cloudy and phase separation soon occurred. The upper phase contained Et₃SiOSiMe₃ and the lower phase contained methanol (eq 1). When we repeated this ex-

$$Me_3SiOMe + Et_3SiOH \rightarrow Me_3SiOSiEt_3 + MeOH$$
 (1)

periment, no cloudiness or phase separation was observed and GC analysis indicated no reaction occurred over the course of several days at room temperature. Indeed, when equimolar amounts of Et₃SiOH and Me₃SiOMe were mixed, sealed in a glass ampule, and heated at 60 °C for a week, no reaction occurred.

A systematic investigation was carried out to discover the source of the discrepancy of observed reactivity. One possibility was that the reactants we used were contaminated with an inhibitor. Alternatively, the reactants employed by Dreyfuss may have been contaminated with a catalyst for the reaction.

The Me₃SiOMe, which was a commercial material distilled from K₂CO₃ prior to use in our studies, was >99% pure by GC analysis. Its elemental analysis was correct and established that it contained <0.1% Cl. The Et₃SiOH employed in our studies was prepared via the hydrolysis of Et₃SiH. The product contained 98% triethylsilanol and 2% hexaethyldisiloxane by GC analysis. The elemental analysis was correct and showed that the sample contained

no Cl. The glassware used in our studies was new and was used as received. We conclude that our reactants were pure and did not contain an inhibitor for the reaction.

The reactants used by Dreyfuss were not pure. The Me₃SiOMe reportedly contained 14% (Me₃Si)₂O even after distillation and the EtaSiOH, which was a commercial material used as received, contained 12% (Et₃Si)₂O.

To determine whether a disiloxane could act as a catalyst in the condensation reaction, we added (Me₃Si)₂O (14%) to Me₃SiOMe before mixing with Et₃SiOH. As expected, no reaction occurred even when the reactants were heated. Therefore it seems unlikely that a disiloxane acted to accelerate the condensation reaction in the Drevfuss studies.

During earlier work in our laboratories, it was found that commercially available silyl ethers often contain impurities that make them highly reactive toward silanols. These impurities generally could not be removed either by simple distillation or by distillation from K₂CO₃. Since silyl ethers are prepared from chlorosilanes, the contaminants were likely to be residual chlorosilanes. Indeed, treatment of these impure silyl ethers with aqueous AgNO3 gave an AgCl precipitate, indicating the presence of active chloride. HCl would be generated upon reaction of a chlorosilane impurity with silanols. HCl is known to be a catalyst for the reaction of silanol with methoxysilane and thus the high reactivity could be explained as a result of the in situ generation of a reaction catalyst.

It appears that the Me₃SiOMe used by Dreyfuss was contaminated with a chlorosilane, probably Me₃SiCl, in addition to the (Me₃Si)₂O contaminant. In an attempt to verify this, various amounts of Me₃SiCl were added to Me₃SiOMe before mixing with Et₃SiOH, and the time lapse from mixing to appearance of cloudiness was noted. When the Me₃SiOMe contained 20–25% Me₃SiCl, a cloudy solution formed within 10–15 s after mixing with Et₃SiOH, just as Dreyfuss described. To see if the same result would be obtained when the Dreyfuss experimental procedure is followed, we fractionally distilled a mixture of 65% Me₃SiOMe, 20% Me₃SiCl, and 15% (Me₃Si)₂O through a 5-in. Vigreux column. The fraction boiling at 58-60.5 °C (uncorrected) was combined with Et₃SiOH, and a cloudy solution formed after about 15 s. When the concentration of Me₃SiCl in Me₃SiOMe was lower, the time lapse between mixing with Et₃SiOH and appearance of cloudiness was longer.

It may seem surprising that 20-25% Me₃SiCl in Me₃SiOMe would not have been detected, but we have found that Me₃SiOMe and Me₃SiCl have the same retention time when Dreyfuss' GC conditions (SE-30 column, 60 °C) are used or when an SE-52 column at 60 °C or even at 30 °C is used. Furthermore, the average molecular weight of a 25% Me₃SiCl in Me₃SiOMe mixture is 105.3, which is within experimental error of the 105.5 value obtained from the MC-2 chromatogram in the previous study. On the basis of this evidence, we conclude that the Me₃SiOMe used in that study must have contained a high concentration of Me₃SiCl contaminant, which caused the Me₃SiOMe to appear highly reactive.

In a previous study carried out in our laboratories, an impure sample of Me₃SiOMe that reacted with Me₃SiOH upon mixing at room temperature was purified by refluxing over and distillation from NaOMe. After distillation from NaOMe, the Me₃SiOMe did not react with Me₃SiOH. Distillation of the impure Me₃SiOMe from K₂CO₃ yielded a sample of Me₃SiOMe that still reacted spontaneously with Me₃SiOH. Presumably, K₂CO₃ would remove any acidic impurities but NaOMe would be required to convert chlorosilane impurities to methoxysilane.

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Table I

% Me ₃ SiCl in Me ₃ SiOMe	result
0.1	no reaction after 30 min
1	~10% Me ₃ SiOSiEt ₃ ^a formed in 30 min
5	solution became hazy in 5 min
10	solution became hazy in 75-90 s
20	solution became hazy in 15 s
25	solution became hazy in 10 s
50	solution became hazy in 5 s

 a M $^{+}$ = 204 in chemical ionization mass spectrometer.

To further illustrate the lack of reactivity between a silanol and silyl ether in the absence of a catalyst, we carried out the following experiment. Me₃SiOH, which reacts 600 times as fast as Et₃SiOH in condensation reactions with silyl ethers,2 was combined with MeSi(OMe)3, which is more reactive than Me₃SiOMe.³ After 30 min of heating at vigorous reflux, no reaction had occurred as shown by GC analysis.

Experimental Section

General Procedures. The silanes and hexamethyldisilazane were purchased from Silar Laboratories and were purified as described below. Gas chromatographic analysis was carried out with either a Hewlett-Packard 5830A gas chromatograph equipped with a 6 ft \times $^1/_4$ in. glass column containing 10% SE-30 on Chromsorb 80/100 W-HP or a Hewlett-Packard 5750 equipped with 4 ft \times $^{1}/_{4}$ in. stainless steel columns containing either 15% SE-52 on 80/100 W-HP 5750 or 15% SE-30 on 80/100 W-HP 5750. Infrared spectra were recorded as thin films on salt plates on a Perkin-Elmer 598, and NMR spectra were recorded using CDCl₃ solutions on a Varian T-60 spectrometer. Mass spectrometry was done with a Varian MAT 311A equipped with a combination chemical ionization-electron impact source.

Synthesis of Et₃SiOH. Et₃SiH (51.8 g, 0.45 mol) was dissolved in diethyl ether (96 g), and a mixture of H₂O (25 g, 1.4 mol), CH₃CN (13.3 g), and a small amount of Pd/C was added. The reaction was stirred at room temperature and monitored by GC. After 2 days, the reaction was complete. The top layer was decanted, filtered through Celite, and dried over MgSO₄, and solvent was removed by rotary evaporation. The last traces of CH₃CN were removed from the Et₃SiOH by adding toluene and then distilling the toluene/CH₃CN azeotrope and the excess toluene. The product obtained was 98% Et₃SiOH and 2% (Et₃Si)₂O as established by GC analysis. The IR and NMR spectra were consistent. Anal. Calcd for C₆H₁₆OSi: C, 54.48; H, 12.19; Si, 21.24; Cl, 0. Found: C, 54.77; H, 12.00; Si, 20.16; Cl, <0.01.

Synthesis of Me_3SiOH .⁴ $(Me_3Si)_2NH$ (17.5 g, 0.108 mol) was dissolved in 50 g of diethyl ether and the solution was added to a 500-mL flask containing 12.5 g of H₂O to which several drops of methyl orange indicator had been added. The mixture was stirred vigorously and cooled in a methanol-ice bath. Aqueous HCl (2 N) was added dropwise just until the indicator remained pink (about 70 mL). A small amount of NaHCO₃ was then added until the indicator was orange again. The aqueous and ether layers were separated, the aqueous layer was extracted with 50 mL of ether, and the combined ether fractions were dried over MgSO4. After filtration, the ether was removed under vacuum to yield 18.6 g of Me₃SiOH (95%), which contained ca. 1% Me₃SiOSiMe₃ by GC analysis. The IR and NMR spectra were consistent.

Purification of Me₃SiOMe. Me₃SiOMe obtained from Silar Laboratories was distilled from anhydrous K₂CO₃, bp 56-57 °C, to yield pure Me₃SiOMe in which no impurities could be detected by GC. Anal. Calcd for C₄H₁₂SiO: C, 46.09; H, 11.61; Si, 26.95; Cl, 0. Found: C, 46.32; H, 11.70; Si, 26.42; Cl, 0.04.

Purification of MeSi(OMe)3. Unpurified MeSi(OMe)3 reacted spontaneously with Me₃SiOH at room temperature. Even after the MeSi(OMe)3 was distilled from K2CO3, spontaneous reaction with Me₃SiOH occurred. However, after 20 g of MeSi(OMe)₃ was combined with 1 g of CH₃OH and 0.1 g of NaOMe and fractionally distilled through a 5-in. Vigreux column, bp 102–103 °C, to yield MeSi(OMe)₃ that was pure by GC analysis, no reaction with Me₃SiOH was observed after 30 min at reflux.

Reaction of Me₃SiOMe with Et₃SiOH. Me₃SiOMe (0.39 g, 3.8 mmol) and Et_3SiOH (0.50 g, 3.8 mmol) were mixed and the solution was analyzed by GC. The solution was sealed in a glass ampule and heated at 60 °C for 1 week. The ampule was opened and GC analysis of the solution showed that no reaction had occurred.

In another set of experiments, various amounts of Me₃SiCl were added to Me₃SiOMe before admixture with an equimolar amount of Et₃SiOH, and the room-temperature reaction was followed by GC or by the time required for a hazy solution to form. Results were as in Table I.

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Reaction between Triethylsilanol and Trimethylmethoxysilane

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A few years ago we reported that products of the reaction between triethylsilanol (Et₃SiOH) and trimethylmethoxysilane (Me₃SiOMe) can be observed by gas chromatography (GC) immediately after mixing at room temperature. We noted that the reaction occurred faster and under milder conditions than anticipated on the basis of earlier studies. White and Olson report that, contrary to our earlier observations, Et₃SiOH and Me₃SiOMe do not react spontaneously at room temperature and their mixtures can be stored for long periods without any products being formed.2 White and Olson attribute the rapid reaction observed by us to the probable presence of the catalytic impurity trimethylchlorosilane (Me₃SiCl) and further suggest that the level of impurity is 20-25%. They argue that because Me₃SiOMe and Me₃SiCl have nearly identical boiling points, 57–58 °C and 57 °C, respectively, and similar molecular weights, 104.3 and 108.7, respectively, the presence of the Me₃SiCl could have gone undetected in our study.

Fortunately, we still have on hand a sample of the Me₃SiOMe used in our previous study and were able to characterize it further. Now, measured 6 years after the sample was received, the sample shows the presence of Me₃SiCl by mass spectrometry (direct analysis) (MS) but not by GC-MS. The presumption is that the Me₃SiCl is such a reactive compound that it does not survive intact even under relatively mild GC conditions. Duplicate chlorine analyses by Galbraith Laboratories, Inc., gave